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APPLICATION NO.	FILING DATE	FIRST NAMED INVENTOR	ATTORNEY DOCKET NO.	CONFIRMATION NO.
09/934,334	08/21/2001	Paul R. Berger	3531-0103P	8252
2292 75	90 09/06/2005		EXAMINER	
BIRCH STEWART KOLASCH & BIRCH			KANG, DONGHEE	
PO BOX 747 FALLS CHURCH, VA 22040-0747			ART UNIT	PAPER NUMBER
	, 		2811	
			DATE MAILED: 09/06/200	5

Please find below and/or attached an Office communication concerning this application or proceeding.

	Application No.	Applicant(s)				
	09/934,334	BERGER ET AL.	BERGER ET AL.			
Office Action Summary	Examiner	Art Unit				
	Donghee Kang	2811				
The MAILING DATE of this communication appears on the cover sheet with the correspondence address Period for Reply						
A SHORTENED STATUTORY PERIOD FOR A WHICHEVER IS LONGER, FROM THE MAILI - Extensions of time may be available under the provisions of 37 after SIX (6) MONTHS from the mailing date of this communical - If NO period for reply is specified above, the maximum statutory - Failure to reply within the set or extended period for reply will, by Any reply received by the Office later than three months after the earned patent term adjustment. See 37 CFR 1.704(b).	NG DATE OF THIS COMMUN CFR 1.136(a). In no event, however, may tion. I period will apply and will expire SIX (6) Mo y statute, cause the application to become	VICATION. a reply be timely filed DNTHS from the mailing date of this communication. ABANDONED (35 U.S.C. § 133).				
Status						
 1) Responsive to communication(s) filed on 2a) This action is FINAL. 2b) Since this application is in condition for a closed in accordance with the practice unit 	This action is non-final.					
Disposition of Claims						
4) ⊠ Claim(s) <u>54-92</u> is/are pending in the app 4a) Of the above claim(s) <u>56,57,67,68,73</u> 5) ⊠ Claim(s) <u>55</u> is/are allowed. 6) ⊠ Claim(s) <u>54,58-66,69-72,74-82 and 86-9</u> 7) ☐ Claim(s) is/are objected to. 8) ☐ Claim(s) are subject to restriction	<u>and 83-85</u> is/are withdrawn fi <u>2</u> is/are rejected.	om consideration.				
Application Papers						
9) The specification is objected to by the Ex	aminer.					
10) ☐ The drawing(s) filed on is/are: a) ☐ accepted or b) ☐ objected to by the Examiner.						
Applicant may not request that any objection to the drawing(s) be held in abeyance. See 37 CFR 1.85(a).						
Replacement drawing sheet(s) including the 11) The oath or declaration is objected to by			•			
Priority under 35 U.S.C. § 119						
12) Acknowledgment is made of a claim for foreign priority under 35 U.S.C. § 119(a)-(d) or (f). a) All b) Some * c) None of: 1. Certified copies of the priority documents have been received. 2. Certified copies of the priority documents have been received in Application No 3. Copies of the certified copies of the priority documents have been received in this National Stage application from the International Bureau (PCT Rule 17.2(a)). * See the attached detailed Office action for a list of the certified copies not received.						
Attachment(s) 1) Notice of References Cited (PTO-892) 2) Notice of Draftsperson's Patent Drawing Review (PTO-90) Information Disclosure Statement(s) (PTO-1449 or PTO Paper No(s)/Mail Date	948) Paper N	w Summary (PTO-413) lo(s)/Mail Date of Informal Patent Application (PTO-152) 				

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DETAILED ACTION

Continued Examination Under 37 CFR 1.114

1. A request for continued examination under 37 CFR 1.114, including the fee set forth in 37 CFR 1.17(e), was filed in this application after final rejection. Since this application is eligible for continued examination under 37 CFR 1.114, and the fee set forth in 37 CFR 1.17(e) has been timely paid, the finality of the previous Office action has been withdrawn pursuant to 37 CFR 1.114. Applicant's submission filed on 7-25-05 has been entered.

Claim Rejections - 35 USC § 112

- 2. The following is a quotation of the first paragraph of 35 U.S.C. 112:
 - The specification shall contain a written description of the invention, and of the manner and process of making and using it, in such full, clear, concise, and exact terms as to enable any person skilled in the art to which it pertains, or with which it is most nearly connected, to make and use the same and shall set forth the best mode contemplated by the inventor of carrying out his invention.
- 3. Claim 63 is rejected under 35 U.S.C. 112, first paragraph, as failing to comply with the written description requirement. The claim(s) contains subject matter which was not described in the specification in such a way as to reasonably convey to one skilled in the relevant art that the inventor(s), at the time the application was filed, had possession of the claimed invention. The phrase "the layers... are grown in a chemical vapor deposition (CVD) growth system" is not supported by the disclosure.
- 4. The following is a quotation of the second paragraph of 35 U.S.C. 112:
 - The specification shall conclude with one or more claims particularly pointing out and distinctly claiming the subject matter which the applicant regards as his invention.

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5. Claims 70 & 72 are rejected under 35 U.S.C. 112, second paragraph, as being indefinite for failing to particularly point out and distinctly claim the subject matter which applicant regards as the invention.

Claims 70 & 72 recite the limitation "the substrate". There is insufficient antecedent basis for this limitation in the claim.

Claim Rejections - 35 USC § 102

6. The following is a quotation of the appropriate paragraphs of 35 U.S.C. 102 that form the basis for the rejections under this section made in this Office action:

A person shall be entitled to a patent unless -

(b) the invention was patented or described in a printed publication in this or a foreign country or in public use or on sale in this country, more than one year prior to the date of application for patent in the United States.

7. Claims **54**, **58-60**, **& 62-63** are rejected under 35 U.S.C. 102(b) as being anticipated by Sweeny et al. (Mark Sweeny, "Resonant interband tunnel diodes", Appl. Phys. Lett., pp 546-548, 1989).

Re claim 54, Sweeny et al. teach a method of fabricating an interband tunnel diode, the method comprising the steps of (Fig.1):

layering a n-type bottom injector (I); layering a p-type top injector (IV) adjacent to the bottom injector; and layering a barrier material between the bottom injector and top injector. See pages 546.

Re claims 58 & 59, Sweeny et al. teach the layers in the interband tunnel diode are grown epitaxially, wherein the layers are semiconductor.

Re claim 60, Sweeny et al. teach the epitaxial layers comprised of a group IV alloy.

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Re claims 62-63, Sweeny et al. teach the layers are grown in a molecular bean epitaxial growth system or chemical vapor deposition growth system.

8. Claims 71 & 86-88 are rejected under 35 U.S.C. 102(b) as being anticipated by Gennser et al. (Resonant tunneling of holes through silicon barriers, pp 210-213, J. Vac. Sci. Tech. B 8 (2), 1990).

Re claim 71, Gennser et al. teach a method of fabricating an interband tunneling diode comprising the step of lowering the substrate temperature before growth layers in the interband tunnel diode (See II. Experiment and Discussion).

Re claim 86, Gennser et al. teach the layers are grown epitaxially.

Re claims 87-88, Gennser et al. teach the substrate temperature is lowered at a temperature in the range of 0°C to 500°C.

9. Claims 74-78 are rejected under 35 U.S.C. 102(e) as being anticipated by Broekaert (US 6,218,677).

Re claims 74-75, Broekaert teaches a method of fabricating an interband tunnel diode by heat treating using ambient gas pressure during or after growth of the layers (Col.4, lines 41-67).

Re claims 76-78, Broekaert teaches heat treating the diode at a 700°C which is in the claimed ranges.

Claim Rejections - 35 USC § 103

- 10. The following is a quotation of 35 U.S.C. 103(a) which forms the basis for all obviousness rejections set forth in this Office action:
 - (a) A patent may not be obtained though the invention is not identically disclosed or described as set forth in section 102 of this title, if the differences between the subject matter sought to be patented and the prior art are such that the subject matter as a whole would have been obvious at the time the invention was made to a person having ordinary skill in the art to which said subject matter pertains. Patentability shall not be negatived by the manner in which the invention was made.
- 11. Claims 64-66, 69, & 89-92 are rejected under 35 U.S.C. 103(a) as being unpatentable over Sweeny et al. in view of Larsen et al. (Diffusion of Sb in relaxed SiGe, pp2684-2686, Appl.Phys.Lett. 68 (19), 5 May 1996).

Sweeny et al. do not explicitly teach heat treatment using an inert or reducing atmosphere or moreover a reduction in ambient gas pressure with various temperature and time. Larsen et al. teach heat treatment in a high flow furnace using an argon ambient with the temperature monitored as a function of time to obtain a precise temperature-time set. Temperature between 719 and 1028oC were used for time between 20 min and 24 h. Therefore, it would have been obvious to one of ordinary skill in the art at the time the invention was made to select a proper temperature and time in order to obtain a high crystalline quality layers.

12. Claims 79-82 are rejected under 35 U.S.C. 103(a) as being unpatentable over Broekaert in view of of Larsen et al. (Diffusion of Sb in relaxed SiGe, pp2684-2686, Appl. Phys. Lett. 68 (19), 5 May 1996).

Brokaert teach heat treating the diode but not times. Larsen et al. teach heat treatment between 20 min and 24 h. It would have been obvious to one of ordinary skill Art Unit: 2811

in the art at the time the invention was made to select the heating time in order a desired properties of the diode.

Allowable Subject Matter

13. Claim 55 is allowed.

Conclusion

14. Any inquiry concerning this communication or earlier communications from the examiner should be directed to Donghee Kang whose telephone number is 571-272-1656. The examiner can normally be reached on Monday through Friday.

If attempts to reach the examiner by telephone are unsuccessful, the examiner's supervisor, Steve Loke can be reached on 571-272-1657. The fax phone number for the organization where this application or proceeding is assigned is 571-273-8300.

Information regarding the status of an application may be obtained from the Patent Application Information Retrieval (PAIR) system. Status information for published applications may be obtained from either Private PAIR or Public PAIR. Status information for unpublished applications is available through Private PAIR only. For more information about the PAIR system, see http://pair-direct.uspto.gov. Should you have questions on access to the Private PAIR system, contact the Electronic Business Center (EBC) at 866-217-9197 (toll-free). fing Monghi

> Donghee Kang Primary Examiner Art Unit 2811

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